

ILC IDT WG2 – Sources Subgroup

Polarized Electron Source

My plan is to maintain one slide deck as a living document.

It will grow as I continue to add different Polarized Electron Source (PES) topics.

Joe Grames

Monday, October 12, 2020

Framework of these slides

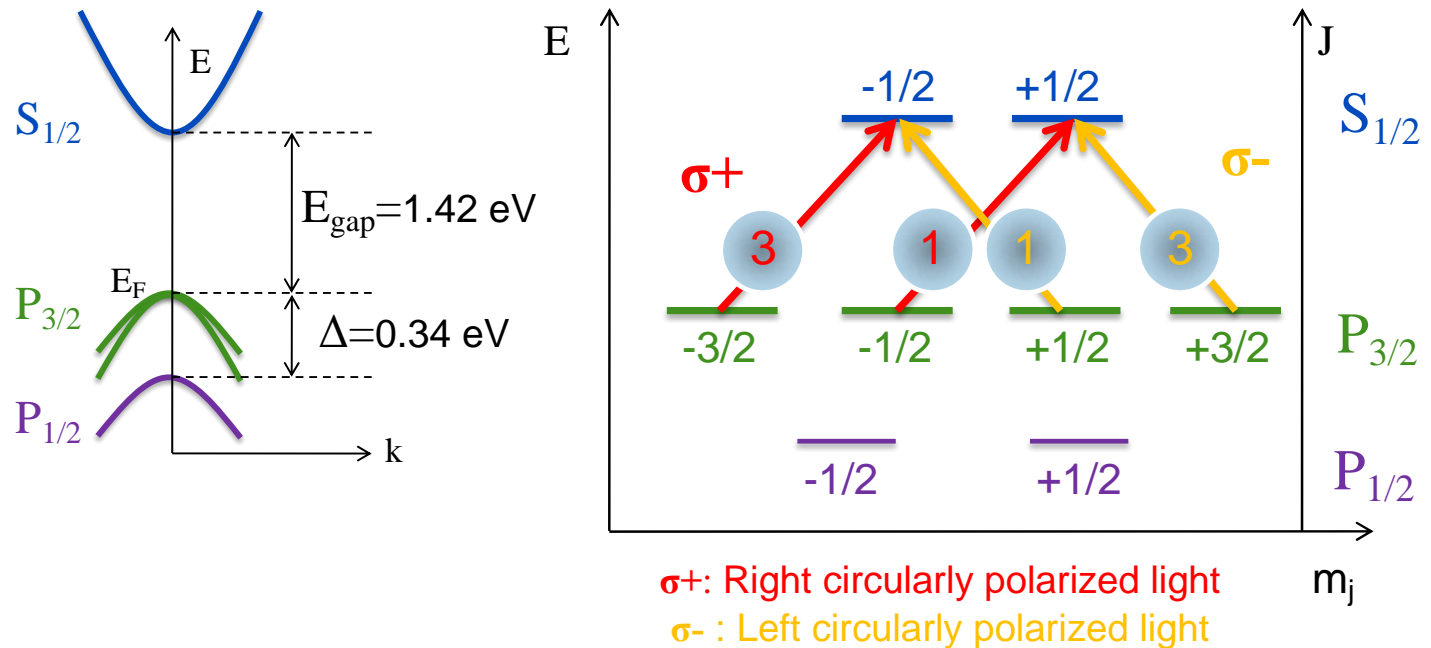
- PES Scope
 - International facilities
 - Summary table alongside ILC requirements
- PES Technologies
 - High polarization photocathodes (GaAs)
 - Extreme high vacuum
 - Reliable high voltage without field emission
 - Drive laser well-matched to photocathode and facility
- PES Performance
 - Photocathode operating lifetime
 - Measured beam qualities

High polarization photocathodes (GaAs)

PES Technologies

- GaAs-based photocathodes

- Revolutionized polarized electron beams at accelerator facilities
- “bulk” material provides 35-40% pol. @ 780nm with QE ~ 20%

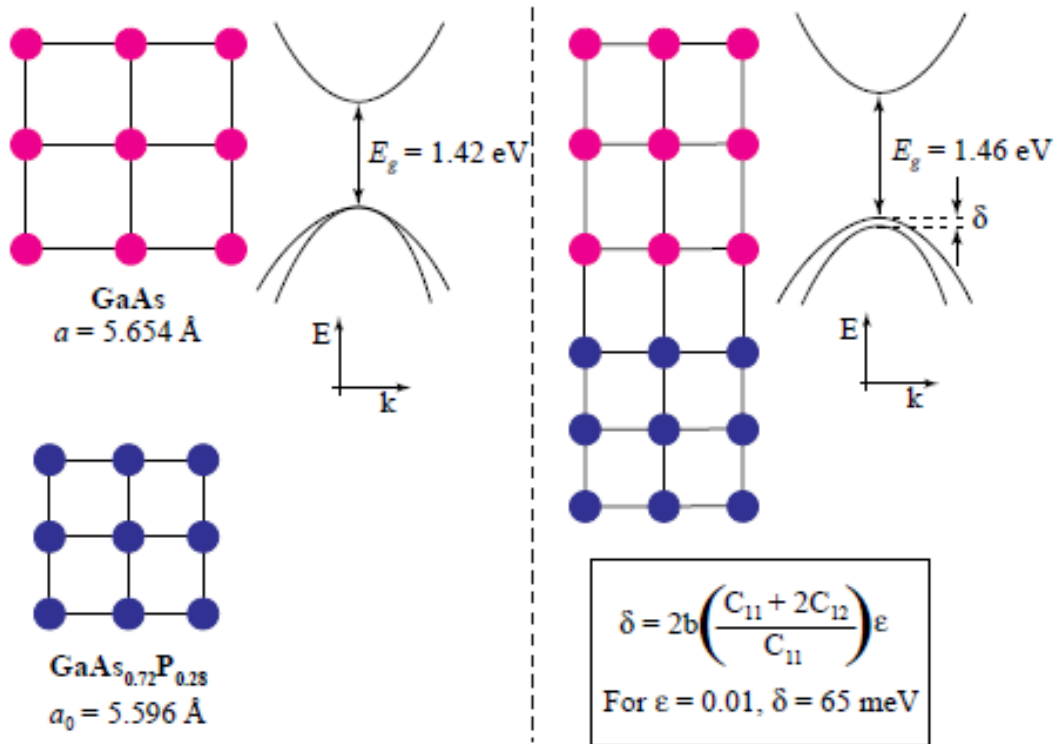


- Laser excitation from $P_{3/2}$ to $S_{1/2}$: $E_{\text{gap}} < E_g < E_{\text{gap}} + \Delta$
- Electron Polarization: $P_e < \frac{3-1}{3+1} = 50\%$
- Reverse electron polarization by reversing light polarization

PES Technologies

- Breaking $P_{3/2}$ degeneracy

Lattice mismatch provides stress



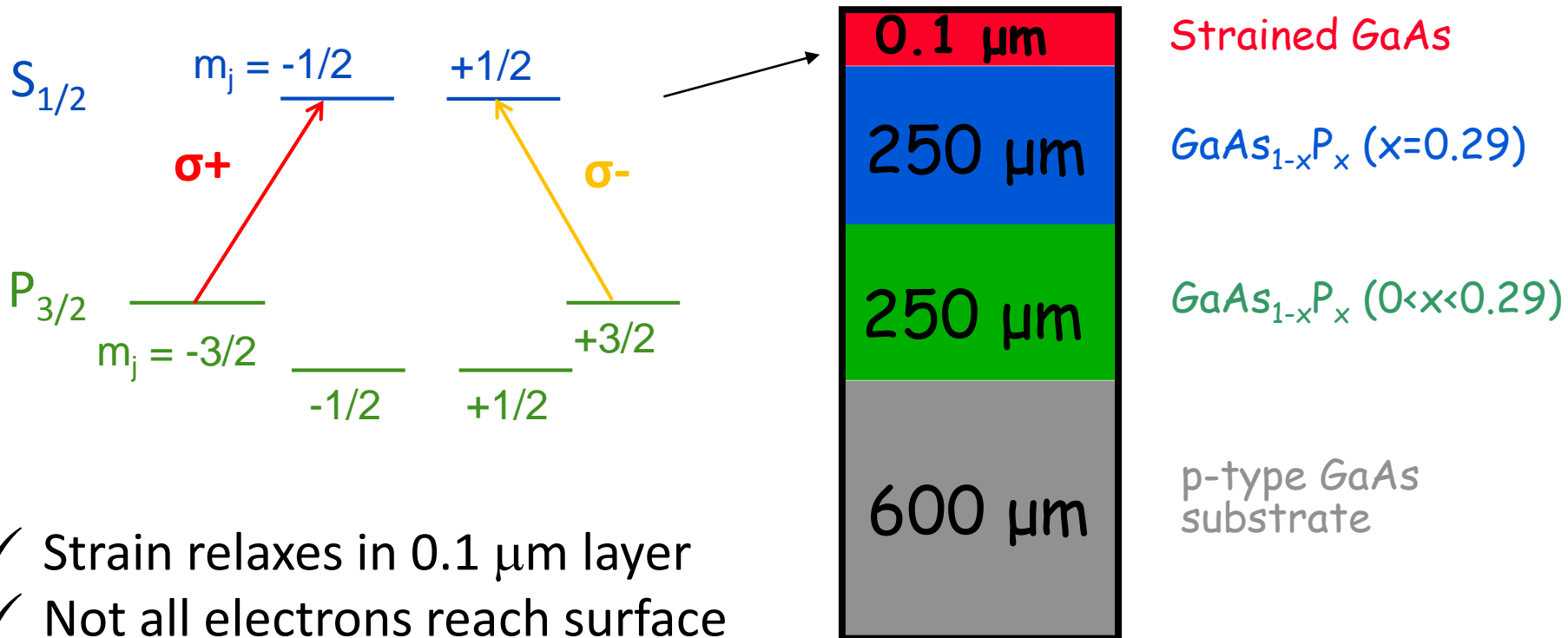
- The band gap of the substrate layer must be larger than surface layer
- Lattice constants must differ enough to introduce suitable strain
- Adjust lattice constant of substrate by varying concentration of third element

Pablo Saez, PhD Thesis, SLAC Report 501, 1997

1% lattice mismatch provides equivalent force as hydraulic press!

PES Technologies

- Strained layer SL-GaAs



- ✓ Strain relaxes in 0.1 μm layer
- ✓ Not all electrons reach surface
- ✓ Polarization 75% \gg 50% 😊
- ✓ QE 0.1% \ll 6% 😞
- ✓ \sim 6% anisotropy in QE 😞

MOCVD-grown epitaxial spin-polarizer wafer

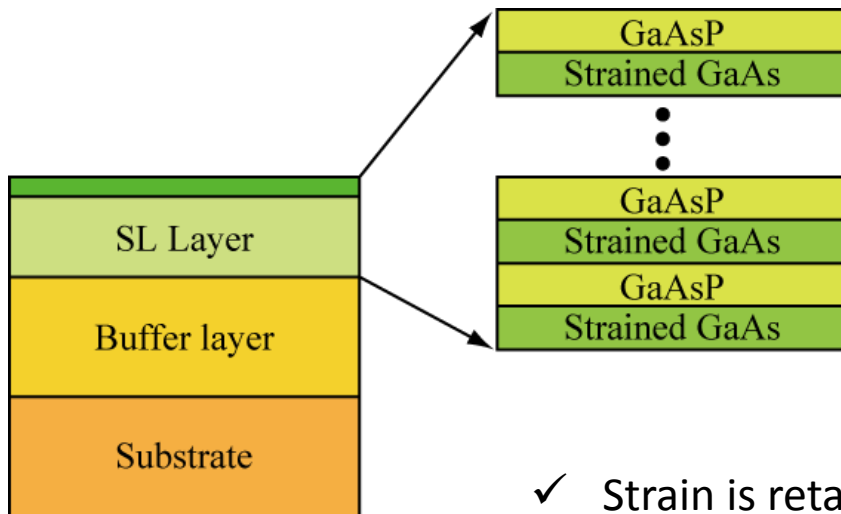
PES Technologies

- Strained Layer Superlattice (SLSP) GaAs

N. Yamamoto¹,

X.G. Jin², A. Mano¹, and Y. Takeda¹

LCWS 2014, 6-10 October 2014



GaAs-GaAs_xP_(1-x) Strained SL

High polarization (> 90%)

QE (~ 0.5 %)

T. Nakanishi et al., NIM A. **455**, 109-112 (2000)

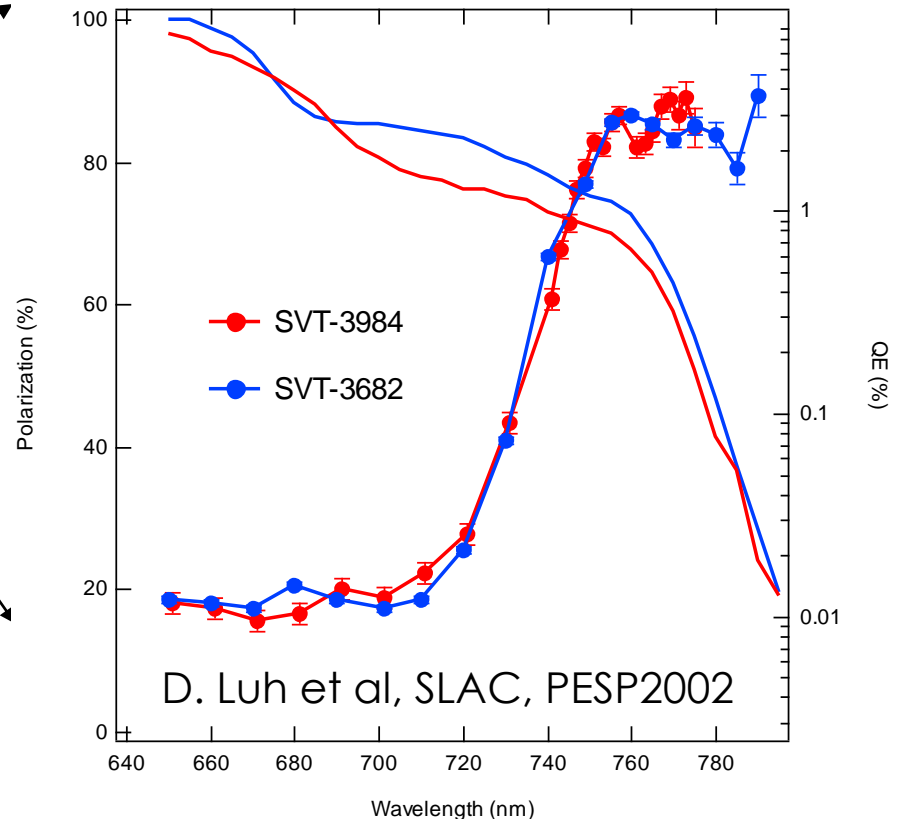
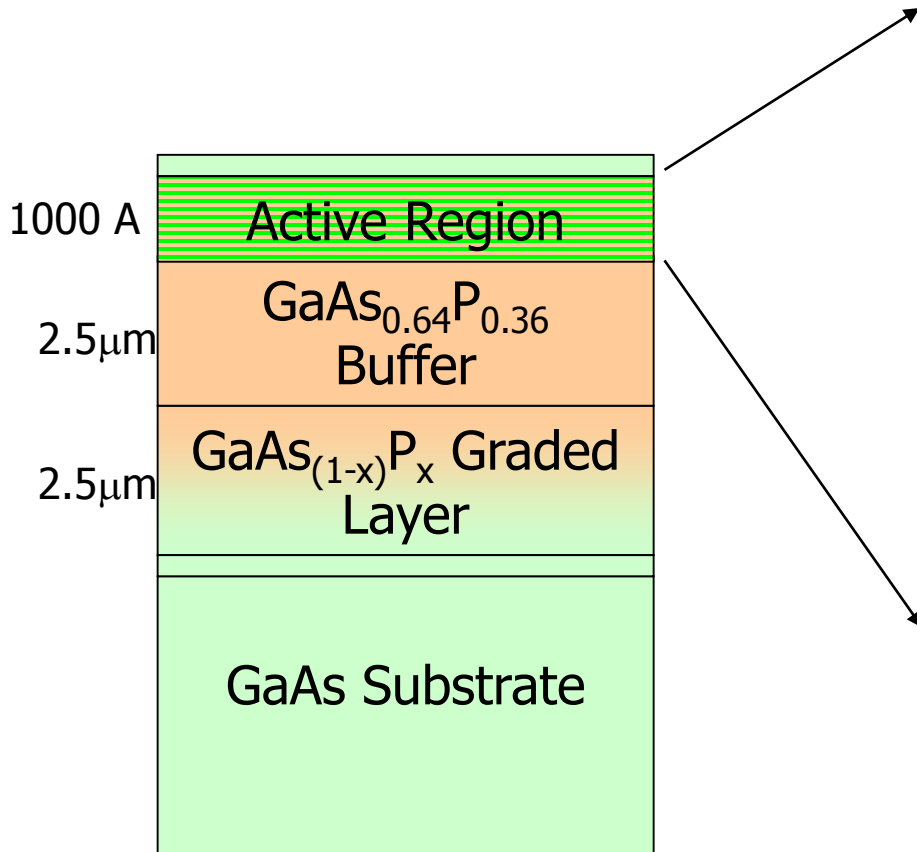
T. Nishitani et al., J. Appl. Phy. **97**, 094907 (2005)

X.G. Jin, et al., APEX, **51**, 108004 (2012)

- ✓ Strain is retained in larger N-layer heterostructure
- ✓ Larger volume ~100 nm within optical absorption thickness
- ✓ Electrons tunnel in quantum well structure toward surface

PES Technologies

- SLSP GaAs/GaAsP experience at Jefferson Lab



QE 1% and Polarization 85%

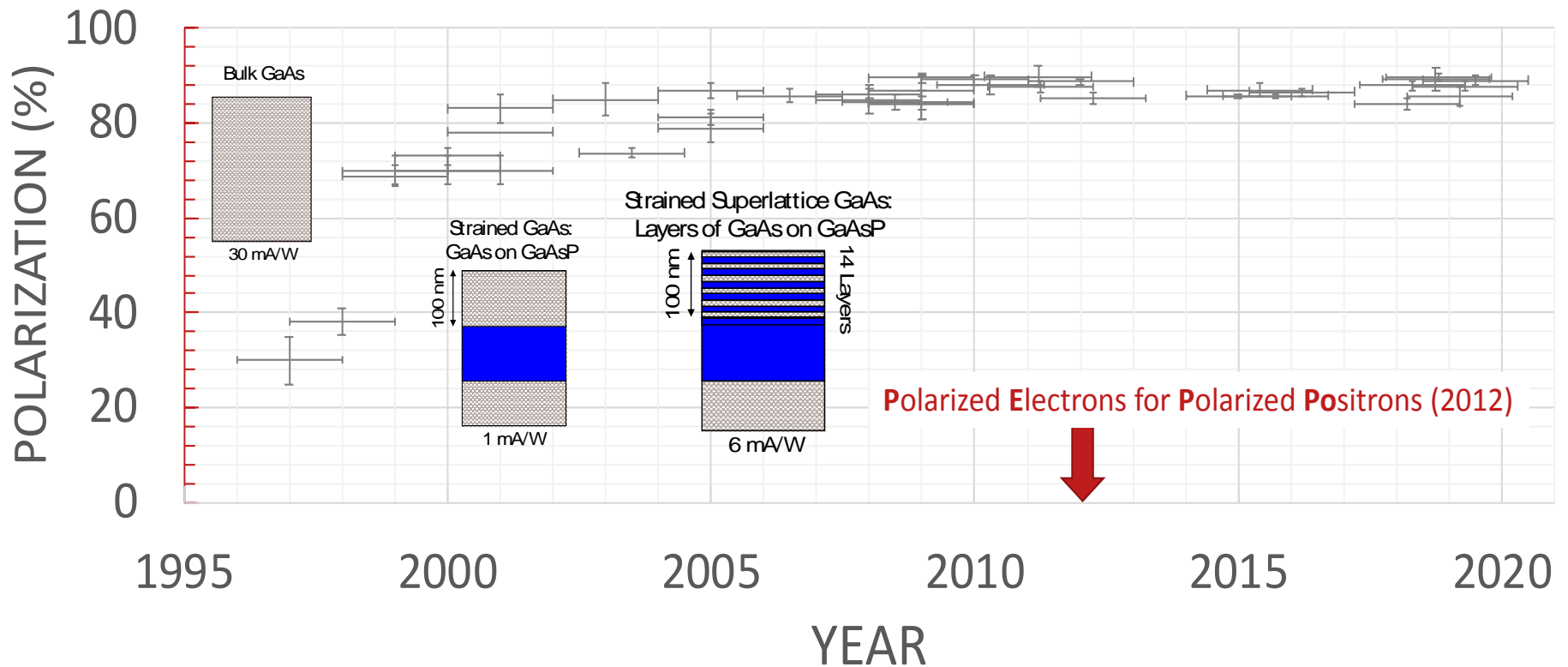


From Aaron Moy, SVT Assoc and SLAC, PESP2002

PES Technologies

- Physics program at JLab motivated US Dept. of Energy funding

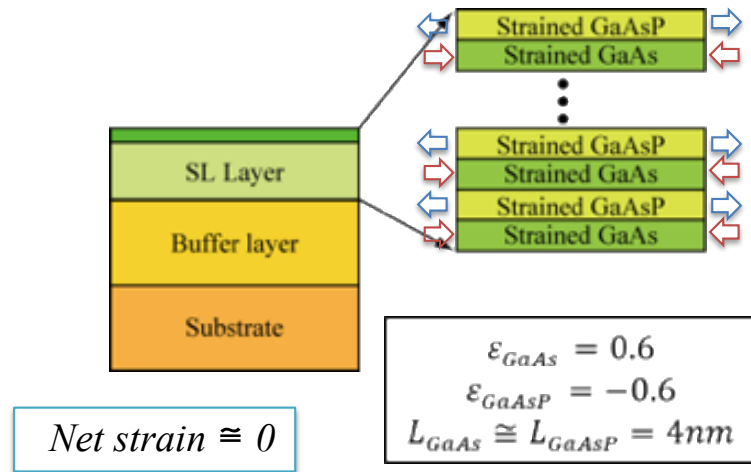
CEBAF Electron Polarization



PES Technologies

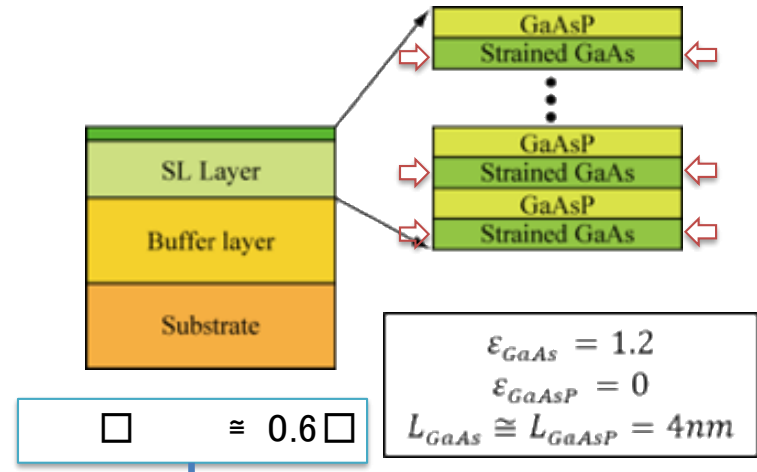
- Strain compensated SLSP (X.G. Gin *et al.*)

Strain-compensated SL



High Crystal Quality
 Higher Electron Polarization
 Higher QE (Thickness SL layers)

Strained SL



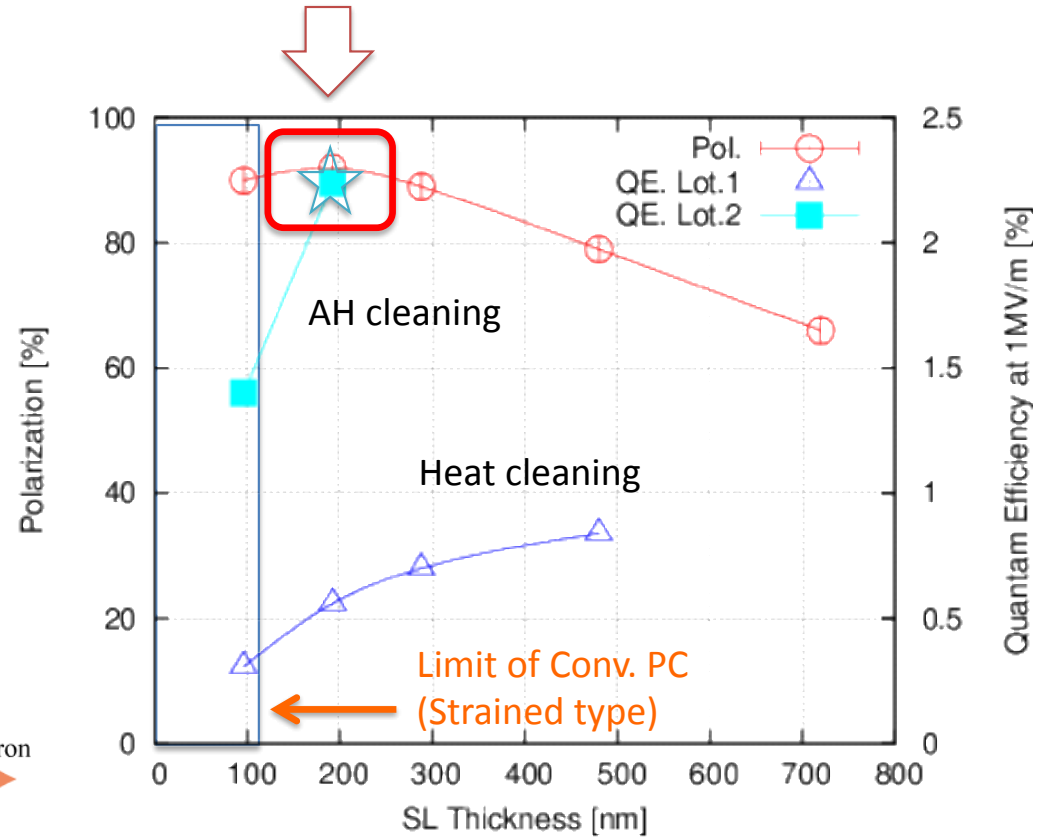
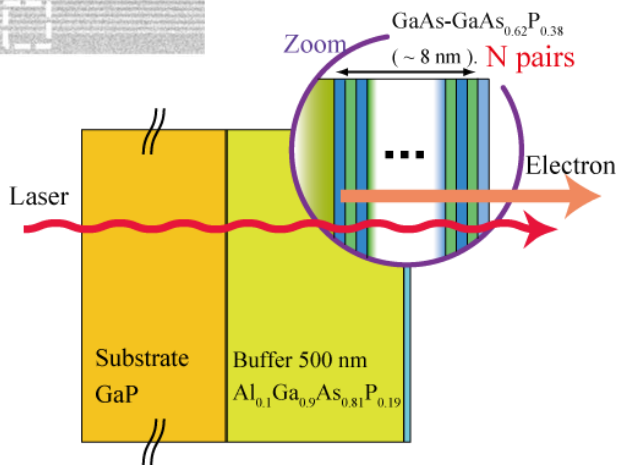
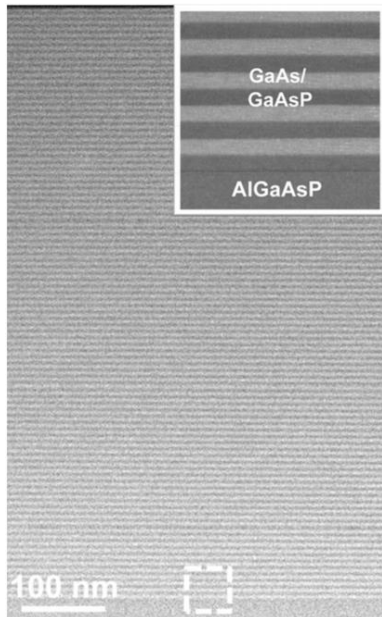
Strain accumulation and
Bad SL structure quality

$$\text{Net strain} = \frac{\epsilon_{GaAs} \cdot L_{GaAs} + \epsilon_{GaAsP} \cdot L_{GaAsP}}{L_{GaAs} + L_{GaAsP}}$$

ϵ : Strain values for each SL layer
 L : Thickness period of each SL layer

PES Technologies

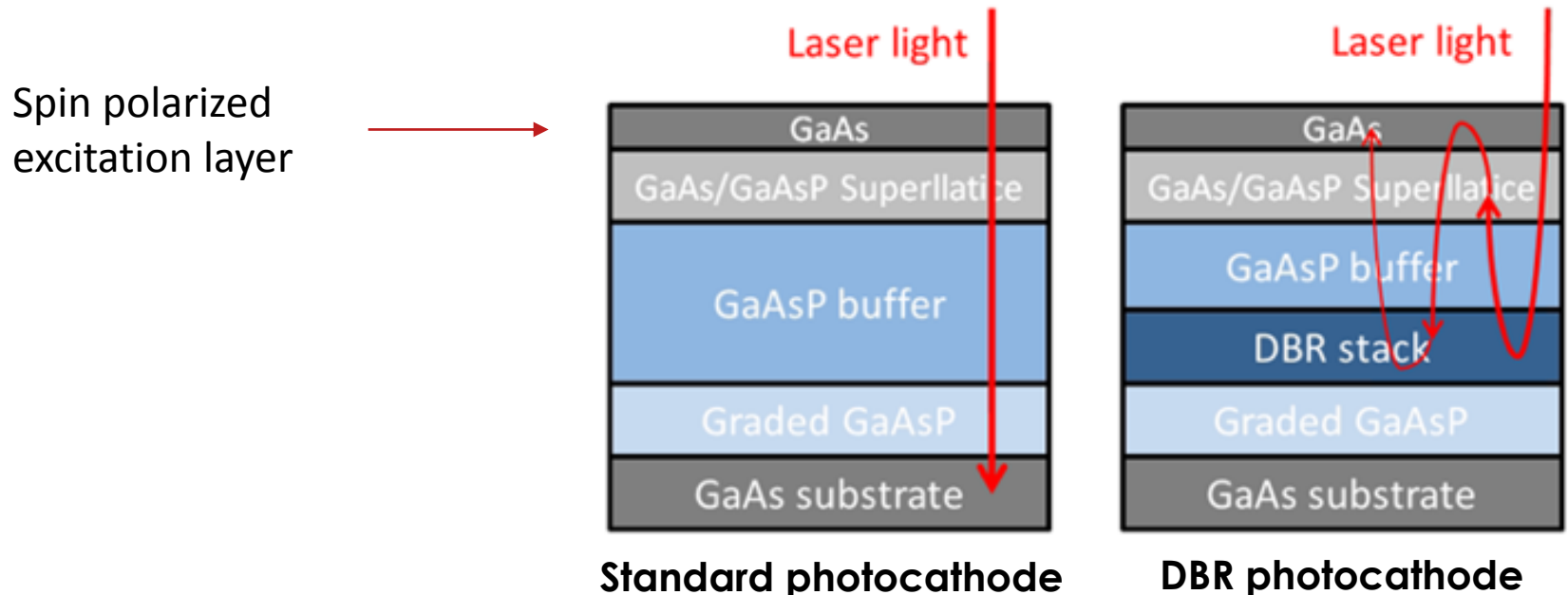
- Strain compensated SLSP (X.G. Gin *et al.*)



PES Technologies

- Diffracted Bragg Reflector SLSP

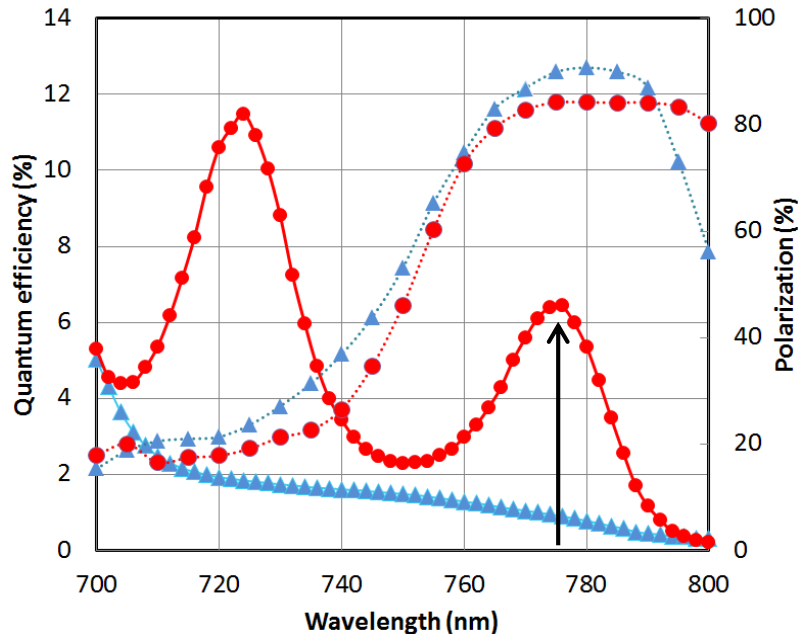
- **Standard Photocathode** : absorption $< 5\%$ in the GaAs/GaAsP superlattice
 - Most light passes into the substrate leading to unwanted heating
- **DBR photocathode** : absorption $> 20\%$ in the GaAs/GaAsP superlattice
 - Less light required to make required beam, less light means less heat



PES Technologies

• Diffracted Bragg Reflector SLSP

W. Liu, S. Zhang, M. Stutzman, M. Poelker, Y. Chen, W. Lu, and A. Moy, Appl. Phys. Lett. **109**, 252104 (2016)



➤ DBR strained-superlattice

- **QE = 6.4%**
- **Polarization = 84%**

➤ Standard strained-superlattice

- QE ~1 %
- Polarization ~90 %

- The highest reported QE of any high polarization photocathode
- Candidate for EIC, polarized positrons
- U.S. DOE SBIR partnership

Cathode	Lab	P(%)	QE (%)	FOM (P ² QE)
GaAs-GaAsP	SLAC/SVT	86	1.2	0.89
AlInGaAs-AlGaAs	St. Petersburg	92	0.85	0.72
GaAs-GaAsP	Nagoya	92	1.6	1.35
GaAs-GaAsP/DBR	JLab/SVT	84	6.4	4.52

PES Technologies

- Long rich history for high polarization photocathodes
 - Breakthroughs first in academic setting
 - Lessons learned moved to commercial semiconductor vendors (US)
- Breaking the 50% theoretical limit ($P > 80\%$, $QE \sim 0.1\%$)
 - Maruyama et al at Univ. California Berkeley InGaAs/GaAs $P > 70\%$
 - Soon after demonstrations at Nagoya University (Japan) and St. Petersburg Technical University (Russia)
- Solving the QE crisis (strained superlattice GaAs)
 - Thin-layer pairs solved strain relaxation, yielding $P > 80\%$ & $QE \sim 1\%$
 - SLAC, Nagoya, St. Petersburg all pioneered the superlattice
- Commercial vendors
 - SLAC teamed up with vendors in DOE SBIR/STTR program
 - SPIRE/Bandwidth Semiconductor => strained GaAs by MOCVD
 - SVT Associates => superlattice by MBE
 - Very reliable performance

PES Technologies

- Present commercial perspective
 - After SLAC repurposed as Light Source JLab teamed up with SVT
 - They later produced the distributed Bragg reflector with QE ~ 6%
 - Unfortunately, SVT no longer sells this material or plans future R&D
- The challenge now is to restore a source of photocathodes !!!
- It is a global challenge:
 - US
 - In FY21 two new 2-year R&D projects are funded
 - **JLab/BNL/Old Dominion University** – test growth process of superlattice by MOCVD and compare to MBE quality
 - **JLab/Univ. California Santa Barbara** – test CBE (chemical beam epitaxy) as alternative to using hazardous solid/gaseous phosphorous of MBE
 - **Euclid Techlabs** has partnered with BNL/Jlab/universities in polarized photocathode R&D, and is proposing to envision a superlattice production facility for EIC, JLab, others...
 - Partner with photocathode workshops (Snowmass, P3, PSTP)
 - Japan
 - What is status of R&D, plans for SuperKEK-B and strain compensated SLSP?
 - Europe
 - What is status of R&D, plans for MESA, Darmstadt, CERN?